

Special Issue

New Trends in Chemical Looping

Message from the Guest Editors

This Special Issue on “New Trends in Chemical Looping” seeks high-quality works covering the latest progress in low-carbon and clean production from the chemical-looping concept. Topics include but are not limited to:

- Innovative oxygen-carrying or multifunctional materials;
- Novel concept or application of the chemical-looping process;
- New solutions to the issues on chemical looping, e.g., agglomeration, attrition, etc.;
- New demonstration or reactor design of the chemical-looping process.

Guest Editors

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Deadline for manuscript submissions

closed (20 August 2024)



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Editor-in-Chief

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